

# United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/805,872	03/22/2004	John L. Caldwell	108298770US	9880
25096	7590 12/23/2005		EXAMINER	
PERKINS COIE LLP			NGUYEN, JIMMY	
PATENT-SEA P.O. BOX 124	-		ART UNIT	PAPER NUMBER
	/ /A 98111-1247		2829	

DATE MAILED: 12/23/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

	A U Al		a.a.
	Application No.	Applicant(s)	U.
Office Action Summany	10/805,872	CALDWELL ET AL.	
Office Action Summary	Examiner	Art Unit	
TI MANUAL DATE AND	Jimmy Nguyen	2829	<del></del>
The MAILING DATE of this communication a Period for Reply	ppears on the cover sheet w	ith the correspondence addre	ess
A SHORTENED STATUTORY PERIOD FOR REF THE MAILING DATE OF THIS COMMUNICATION  - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a r  - If NO period for reply is specified above, the maximum statutory perion  - Failure to reply within the set or extended period for reply will, by state than three months after the may be a searched patent term adjustment. See 37 CFR 1.704(b).	N. 1.136(a). In no event, however, may a eply within the statutory minimum of thiod will apply and will expire SIX (6) MOI ute, cause the application to become A	reply be timely filed rty (30) days will be considered timely. NTHS from the mailing date of this comn BANDONED (35 U.S.C. § 133).	nunication.
Status			
1) Responsive to communication(s) filed on 17	October 2005.		
<u> </u>	nis action is non-final.		
3) Since this application is in condition for allow closed in accordance with the practice unde	•	• •	nerits is
Disposition of Claims			
4) ☐ Claim(s) 17 - 37 is/are pending in the application Papers  4a) Of the above claim(s) is/are withd  5) ☐ Claim(s) 24 is/are allowed.  6) ☐ Claim(s) 17 - 23, 25 - 37 is/are rejected.  7) ☐ Claim(s) is/are objected to.  8) ☐ Claim(s) are subject to restriction and are subject to restriction and are subject to restriction and are subjected to by the Examination of the drawing(s) filed on 22 March 2004 is/are Applicant may not request that any objection to the	rawn from consideration. I/or election requirement. ner. :: a)⊠ accepted or b)⊟ ob	· ·	
Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the	,	• • •	` '
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:  1. Certified copies of the priority docume 2. Certified copies of the priority docume 3. Copies of the certified copies of the priority docume application from the International Bure * See the attached detailed Office action for a life.	ents have been received.  Ints have been received in Actionity documents have been eau (PCT Rule 17.2(a)).	Application No  received in this National Sta	age
Attachment(s)	4) 🖂 Interview	Cummery (DTO 442)	
<ol> <li>Notice of References Cited (PTO-892)</li> <li>Notice of Draftsperson's Patent Drawing Review (PTO-948)</li> <li>Information Disclosure Statement(s) (PTO-1449 or PTO/SB/O Paper No(s)/Mail Date</li> </ol>	Paper No(	Summary (PTO-413) s)/Mail Date Informal Patent Application (PTO-15 	52)

#### **DETAILED ACTION**

## **Response to Argument**

Applicant's arguments, filed 10/17/05, with respect to the rejection(s) of claim(s) 17 – 37 have been fully considered and are persuasive. Therefore, the rejection has been withdrawn. However, upon further consideration, a new ground(s) of rejection is made.

## Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 17 23, 25 37 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sato et al (US 6,707,309) in view of Akram et al (US 6,373,273).

As to claims 17, 26, 32, 37, Sato et al disclose (fig 1)

A test socket (24) for receiving a microfeature device (26) having a substrate and a plurality of interconnect elements (26a) projecting from the substrate (26), the test socket (24) comprising a recess (open middle section) having a lead-in surface (open surface) and a support surface (upper surface 24), the support surface (30, 32).

However, Sato et al are silent on a plurality of apertures positioned to receive corresponding interconnect elements of the microfeature device, wherein the individual aperture extend through the test socket and have a cross-sectional dimension less than

Art Unit: 2829

a cross-sectional dimension of the interconnect elements so that the substrate is spaced apart from the support surface when the microfeature device is received in the recess.

On the other hand, Akram et al teach (fig 29) a plurality of apertures (16) positioned to receive corresponding interconnect elements (14) of the microfeature device(12), wherein the individual aperture (16) extend through the test socket (10) and have a cross-sectional dimension less than a cross-sectional dimension of the interconnect elements (14) ( the cross section of pocket 16 is less than the cross section of contact 14) so that the substrate (12, 32) is spaced apart from the support surface (top surface of 10) when the microfeature device (12) is received in the recess (16).

It would have been obvious to one having an ordinary skill in the art at the time of the invention was made to modify the teaching of Sato et al with the aperture as taught by Akram et al for the purpose ensuring the contact between the semiconductor devices with the socket.

As to claims 18, 29, 35, Akram et al teach (fig 29) the test socket of claim 17, wherein the apertures (16) in the support columns corresponding to an array of interconnect elements (14) on the microfeature device (12).

As to claims 19, 30, 36, Akram et al teach (fig 29) the test socket of claim 17 wherein:

Application/Control Number: 10/805,872

Art Unit: 2829

the support surface (the upper surface of 10) further comprises an opening, and the apertures (16) in the support surface are arranged around the perimeter of the opening so that when the microfeature device (12) is received in the recess, the apertures (16) receive the corresponding interconnect elements (14) and the other interconnect elements are positioned at the opening.

As to claim 20, Akram et al teach (fig 29) the support surface (the upper surface 10) further comprises an opening, and the apertures (16) comprise at least three apertures around the opening.

As to claim 21, Akram et al teach (fig 29) the test socket (10) of claim 17 wherein the cross-sectional dimension of the individual apertures (16) is from approximately 70 percent to approximately 80 percent of the cross-sectional dimension of the corresponding interconnect elements (14).

As to claims 22, 31, Sato et al disclose (fig 1) the test socket of claim 17, further comprising:

a body having the recess (middle section opening) and a shelf (30b), and a ball support member carried by the shelf (30b) and having the support surface.

As to claim 23, Akram et al teach (fig 29) the test socket of claim 17 wherein the individual apertures (16) comprise a beveled portion.

As to claims 25, 28, 34, Akram et al teach (figs 27 - 29) the test socket of claim 17 wherein: the cross-sectional dimension of the individual apertures (16) is a first, smallest diameter in the apertures; and the individual apertures comprise a first portion having the first, smallest diameter and a second portion having a second diameter greater than the first diameter.

As to claims 27, 33, Akram et al teach (fig 29) the test socket (10) wherein the individual apertures (16) have a cross sectional dimension less than a cross sectional dimension of the corresponding interconnect element (14).

## Allowable Subject Matter

## 3. Claim 24 is allowed.

The prior arts of record are fail to disclose the combination of a test socket for receiving a microfeature device having a substrate and a plurality of interconnect elements projecting from the substrate, the test socket comprising a recess having a lead-in surface and a support surface, the support surface including a plurality of apertures positioned to receive corresponding interconnect elements of the microfeature device, wherein the individual apertures extend through the test socket and have a cross-sectional dimension less than a cross-sectional dimension of the interconnect

Art Unit: 2829

elements so that the substrate is spaced apart from the support surface when the microfeature device is received in the recess, wherein the test socket further comprises an exterior surface opposite the support surface, and wherein the individual apertures comprise a first beveled portion proximate to the support surface and a second beveled portion proximate to the exterior surface.

### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jimmy Nguyen whose telephone number is (703) 306-5858. The examiner can normally be reached on M-F from 9 to 5.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Ramtez Nestor can be reached on 571-272-2034. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Application/Control Number: 10/805,872

Art Unit: 2829

Jimmy Nguyen

12/17/05

VINH NGUYEN
PRIMARY EXAMINER

Page 7

Au-2829 12/19/05